

Kinetic modelling of O₂ discharges

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Self-consistent kinetic model

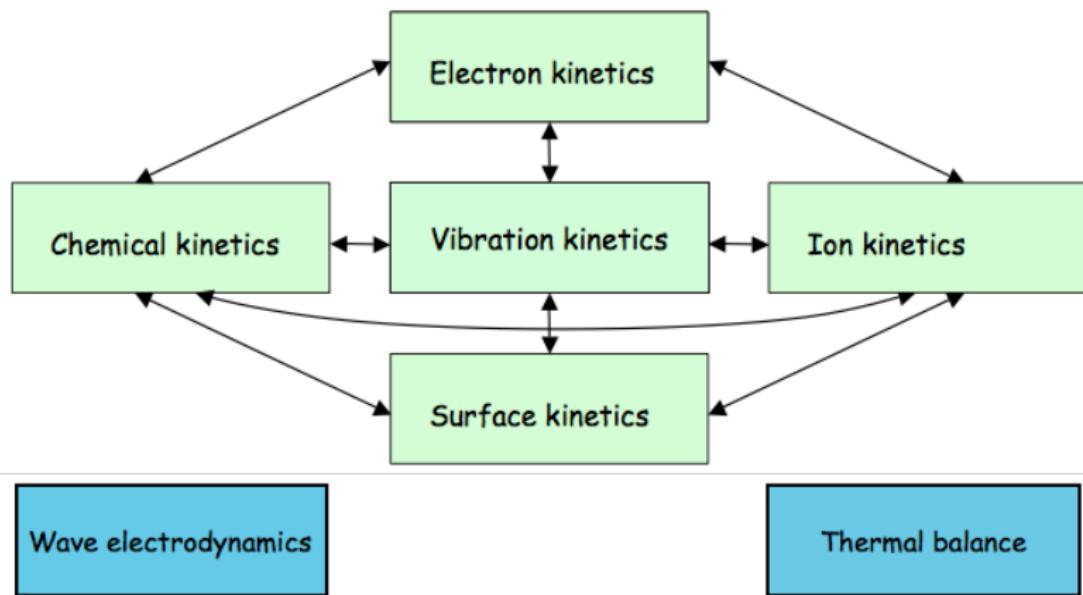
Input

- Discharge operating parameters (p , R , P or n_e , ω)
- Wall temperature
- Gas temperature
- Collisional data (see IST-Lisbon database @ LXCat)

Output

- Sustaining electric field
- Electron energy distribution function (EEDF)
- Vibration distribution functions (VDF)
- Concentration of electronically excited states and ions
- Gas temperature
- Wave number and attenuation coefficient

Self-consistent model



The LoKI code

LoKI (LisbOn KInetics)

- Electron kinetics (electron Boltzmann equation in the mixture O₂-O)
[L.L. Alves *et al*, *Eur. Phys. J. D.* **70** (2016) 1]
- Vibrational kinetics of O₂(X $^3\Sigma_g^-$, ν') molecules
- Chemical kinetics of O₂(a, b), O(3P , 1D), O₃ and O₃^{*}
- Ion kinetics of ion kinetics of O₂⁺, O⁺ and O⁻
- Electrons and ion transport + quasi-neutrality (self-consistent E/N)

[V. Guerra and J. Loureiro, *Plasma Sources Sci. Technol.* **8** (1999) 110]

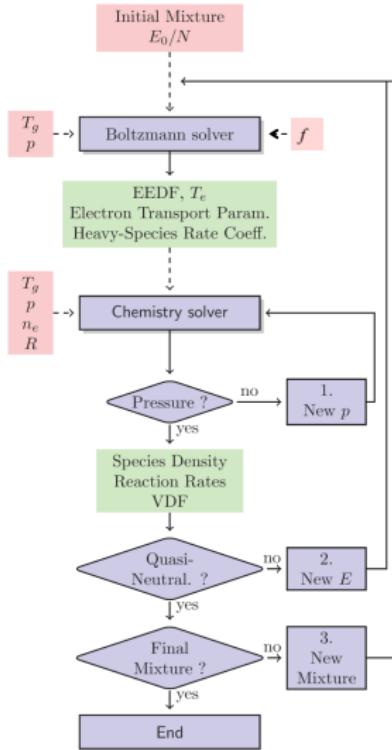
A word on surface kinetics

- Usually treated as a separate module
- No conceptual problem in coupling gas phase and surface kinetics

[V. Guerra *et al*, *J. Phys D: Appl. Phys.* **47** (2014) 224012]

[V. Guerra and D. Marinov, *Plasma Sources Sci. Technol.* **25** (2016) 045001]

The LoKI workflow (stationary case)



In this lecture

Illustrations

- vibrationally excited O_2 (*cf.* previous lecture by J.P. Booth!)
- O_3 kinetics in low-pressure discharges
- A glimpse at surface kinetics

#1 Vibrationally excited O₂(X $^3\Sigma_g^-$, v')

In collaboration with

- J.P. Booth, M. Foucher, D. Marinov, A. Gibson, O. Guaitella (LPP)
- A. Annušová (Comenius University at Bratislava)
- M.Lino da Silva (IPFN, IST)
- B. Lopez (Univ. Illinois at Urbana)

Vibrationally excited O₂

- Recent experiments have revealed highly excited O₂(X, v) in pure O₂ ICP and DC discharges
[M. Foucher *et al*, *Plasma Sources Sci. Technol.* **24** (2015) 042001]
- The challenge: develop a detailed O₂(X, v) kinetics
 - Updated rates for V-V and V-T transfers in collisions with O₂
 - Updated rates for V-T transfers in O₂-O collisions
 - Updated rates for e-V processes
 - Description of e-dissociation from v-levels

Vibrational kinetics of O₂(X)

- VT O₂-O₂: $O_2(X, v) + O_2 \rightleftharpoons O_2(X, v - 1) + O_2$
- VV O₂-O₂: $O_2(X, v) + O_2(w) \rightleftharpoons O_2(X, v - 1) + O_2(w + 1)$

[C. Coletti and G.D. Billing, *Chem. Phys. Lett.* **356** (2002) 14]

[M. Lino da Silva *et al*, *Chem. Phys. Lett.* **531** (2012) 28]

- VT O₂-O: $O_2(X, v) + O \rightleftharpoons O_2(X, v') + O$
[F. Esposito *et al*, *Chem. Phys.* **351** (2008) 91]

- e-V: $e + O_2(X, v) \rightleftharpoons e + O_2(X, w)$
- e-D: $e + O_2(X, v) \rightarrow e + O + O$
- e-A: $e + O_2(X, v) \rightarrow O + O^-$

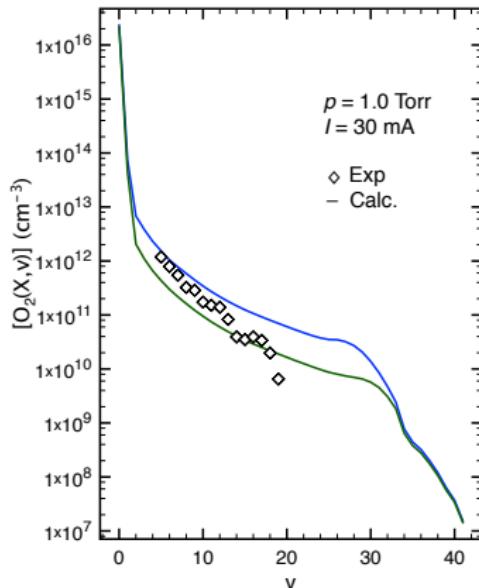
[V. Laporta *et al*, *Plasma Sources Sci. Technol.* **22** (2013) 025001]

[R. Celiberto *et al*, *Open Plasma Phys. J.* **7** (2014) 33]

- Wall: $e + O_2(X, v) \rightarrow e + O_2(X, v - 1)$

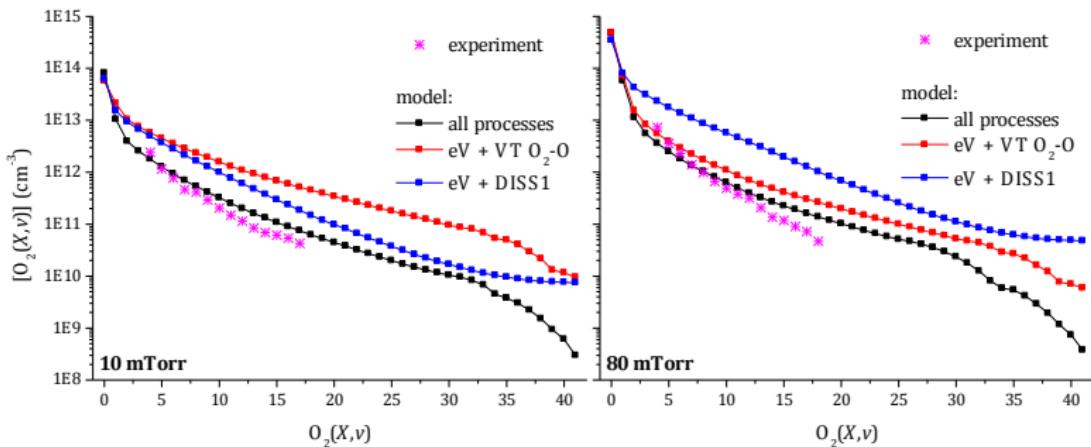
Results: O₂ DC discharge

- Experiments by M. Foucher, D. Marinov, O. Guaitella and J.P. Booth
- e-V + V-T O₂-O
- The good agreement is extended to other values of I , p and to ICP
- For lower pressures
 $e + O_2(X, v) \rightarrow e + O + O$ becomes important

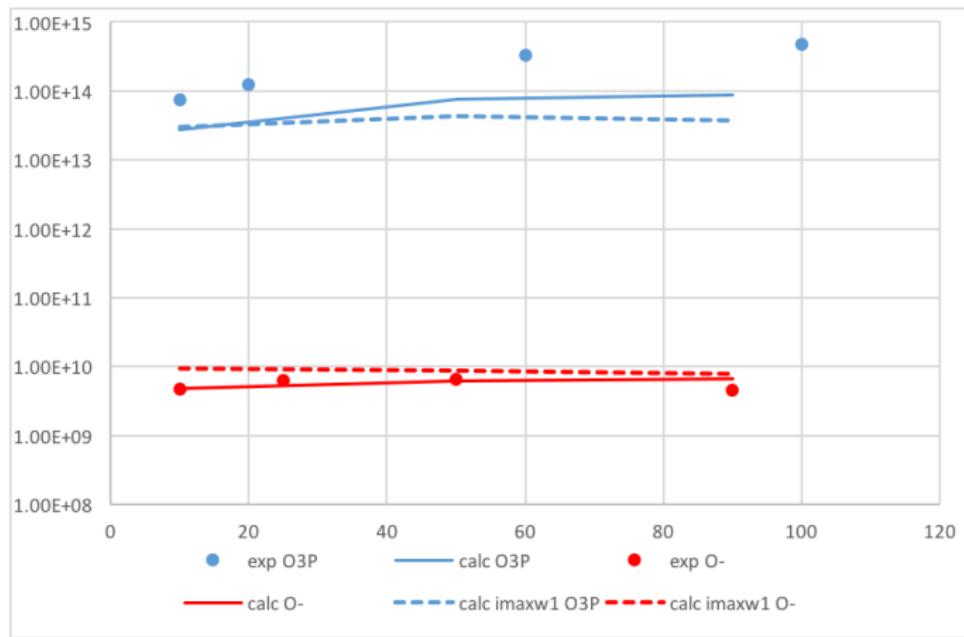


$$(\text{—}) \gamma_O = 2 \times 10^{-3};$$
$$(\text{—}) \gamma_O = 8 \times 10^{-3}$$

Results: O₂ ICP discharge



Results: Influence of the EEDF



#2 vibrationally excited ozone

In collaboration with

- D. Marinov, O. Guaitella, J.P. Booth A. Rousseau (LPP)
[D. Marinov *et al*, *Plasma Sources Sci. Technol.* **22** (2013) 055018]

Motivation

- Ozone kinetics seems quite well established at atmospheric pressure
- What can we learn at lower pressures?
 - Surface processes (O_3 formation at the wall)
 - Role of vibrationally excited ozone (O_3^*)
- Ozone formation at the wall
 - Jansen and Tuzson: “Isotope Evidence for Ozone Formation on Surfaces”
[*J. Phys. Chem. A* **114** (2010) 9709]
 - Lopaev *et al* $\gamma(O_3)$ increases with pressure: $\sim 10^{-3}$ at 10 Torr; $\sim 5 \times 10^{-4}$ at 5 Torr
[*J. Phys. D: Appl. Phys* (2011) **44**]

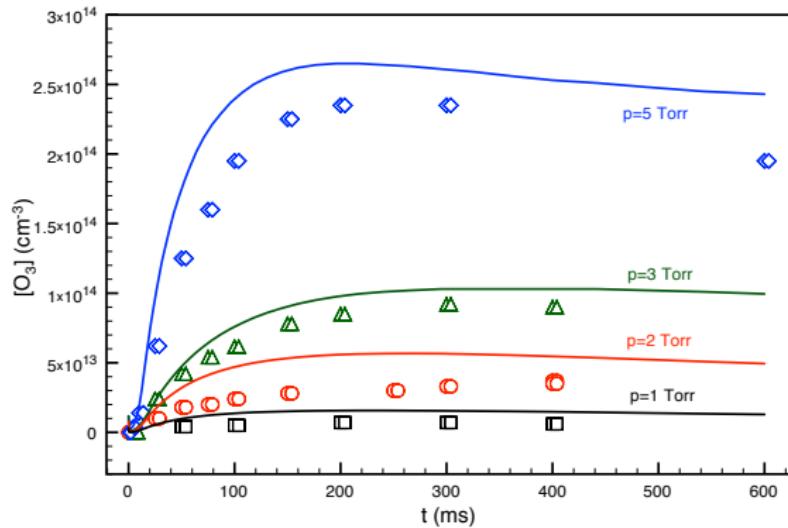
Motivation (continued)

- vibrationally excited ozone
 - Rawlings *et al*: O_3^* is mainly formed on the asymmetric stretching mode ν_3 (00ν)
[*J. Geophys. Res.* **90** (1985) 283]
 - Eliasson *et al* 1987, Eliasson and Kogelschatz 1990
 - $O_2 + O_2 + O \rightarrow O_3 + O_2$ produces O_3 mainly in an excited state
 - O_3^* decreases the absolute value of $[O_3]$
 - O_3^* increases the characteristic time for ozone formation
[*J. Phys. D: Appl. Phys.* **20** (1987) 1421]
 - Lopaev et al 2011: Model with 5 vibration levels of O_3

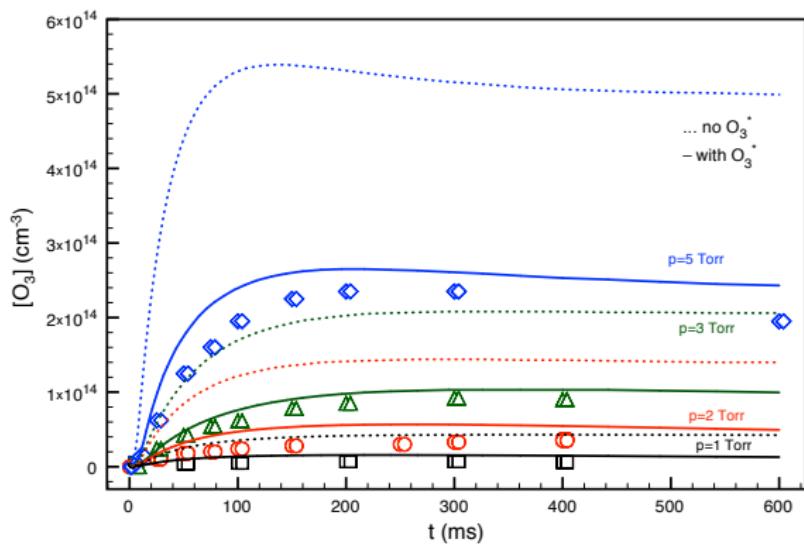
The system under study

- Experiment
 - DC discharge with short pulses (~ 1 ms)
 - Silica tube, $R=1\text{cm}$, $p=1\text{-}5$ Torr
 - Time-resolved measurements of $[\text{O}]$ (TALIF)
 - Time-resolved measurements of $[\text{O}_3]$ (UV absorption)
- Modelling
 - Input: $p, I, R, \Delta t, T_g = 300$ K
 - One effective vibrationally excited level O_3^*
 - Collision rates taken essentially for the (001) level
 - 2/3 of $\text{O}_2 + \text{O}_2 + \text{O} \rightarrow \text{O}_3 + \text{O}_2$ produce O_3^*

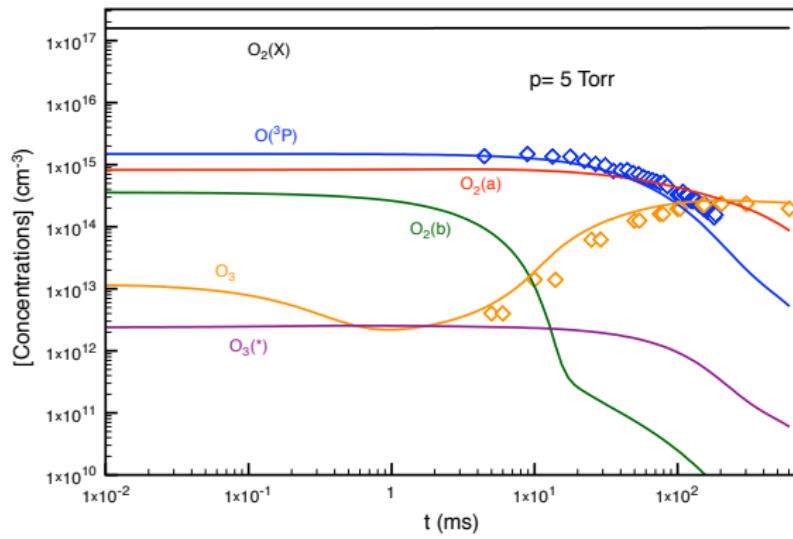
Results: O₃ molecules



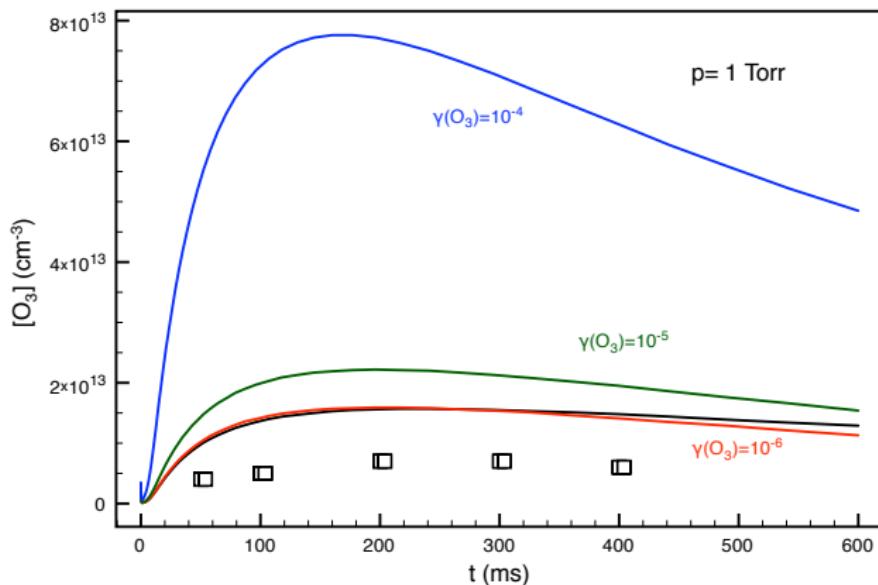
Results: role of O_3^* molecules



Results: species concentrations

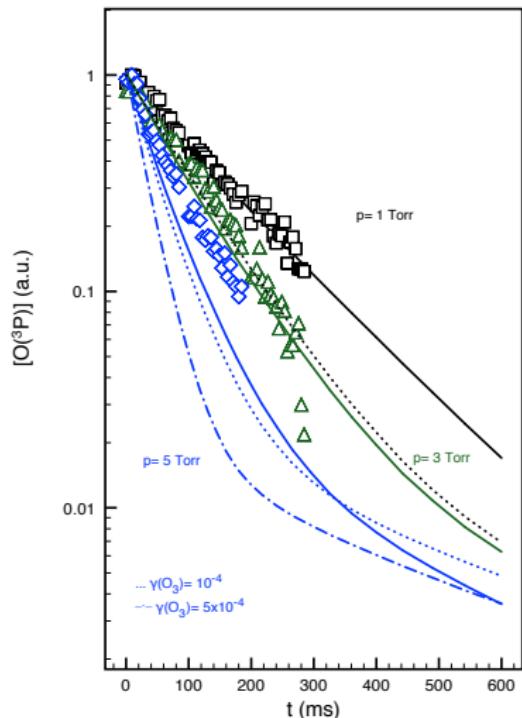


Results: $\gamma(O_3)$



$$p = 1 \text{ Torr}: \gamma(O_3) < 10^{-5}$$

Results: $\gamma(O_3)$



$$p = 5 \text{ Torr:} \\ \gamma(O_3) < 10^{-4}$$

#3 A glimpse at surface

In collaboration with

- D. Marinov (LPP)
- C. Teixeira (IPFN, IST)

[V. Guerra and D. Marinov, *Plasma Sources Sci. Technol.* **25** (2016)
045001]

Modelling surface kinetics

- Macroscopic description
- Atomic scale simulations

[M. Rutigliano *et al*, *PSST* **23** (2014) 045016]

[A. Bogaerts *et al*, *J. Phys. D: Appl. Phys.* **44** (2011) 174030]

[E.C. Neyts and A. Bogaerts, *J. Phys. D: Appl. Phys.* **47** (2014) 224010]

- Application to realistic molecule formation on silica (under plasma conditions) is still difficult
- Coupling with complex gas-phase chemistry unpractical

- Mesoscopic description
 - “coarse-grained” description of the surface
 - lacks predictive power
- ⇒ the best approach for our purpose!

Mesoscopic descriptions

- *Deterministic* approach
 - reaction-rate differential equations

[Y.C. Kim and S. Boudart, *Langmuir* **7** (1991) 2999]
[V. Guerra 2007, *IEEE Trans. Plasma Sci.* **35** (2007) 1397]
[D.V. Lopaev *et al*, *J. Phys. D: Appl. Phys.* **44** (2011) 015201]
- *Stochastic* kinetic (dynamical) Monte Carlo
 - exact and simple to implement
 - describe fluctuations
 - probabilities may depend on local configurations
 - good treatment of physisorbed species
 - bridge the gap between MD and simpler models
 - n -fold way (BKL) algorithm

[V. Guerra and D. Marinov, *Plasma Sources Sci. Technol.* **25** (2016) 054001]

Kinetic Monte Carlo in a nutshell

- Simulate the *time-evolution of the system* without dealing with the *master equation* directly

$$\frac{\partial P(\sigma, t)}{\partial t} = \sum_{\sigma'} [W(\sigma' \rightarrow \sigma)P(\sigma', t) - W(\sigma \rightarrow \sigma')P(\sigma, t)]$$

- Generate “what, where, when”
- n -fold way (BKL algorithm)
 - [A.B. Bortz, M.H. Kalos and J.L. Lebowitz, *J. Comput. Phys.* **17** (1975) 10]
 - [D.T. Gillespie, *J. Phys. Chem.* **81** (1977) 2340]
- Time increment selected randomly from an exponential distribution with parameter $\lambda = \sum_i n_i r_i = \sum_i \lambda_i$

The n -fold way (BKL) algorithm

- chose the next event type, e_j
$$\left(\sum_{i=1}^{j-1} \lambda_i < rand \times \lambda \leq \sum_{i=1}^j \lambda_i \right)$$
- chose the site, *from the list of possible sites for e_j*
- calculate the time increment and update the system

[A.B. Bortz, M.H. Kalos and J.L. Lebowitz, *J. Comput. Phys.* **17** (1975) 10]

[D.T. Gillespie, *J. Phys. Chem.* **81** (1977) 2340]

[V. Guerra and D. Marinov, *Plasma Sources Sci. Technol.* **25** (2016) 054001]

- A new variant: the BKL* algorithm
 - θ_f is quite small ($10^{-7} - 10^{-4}$)
 - huge grids may be necessary in the simulations
 - keeping track of $[F_v]$ is computationally **very expensive**
 - modification of the BKL algorithm: find the site with a null-event scheme!
- ⇒ can be up to 20% faster!

The n -fold way (BKL) algorithm

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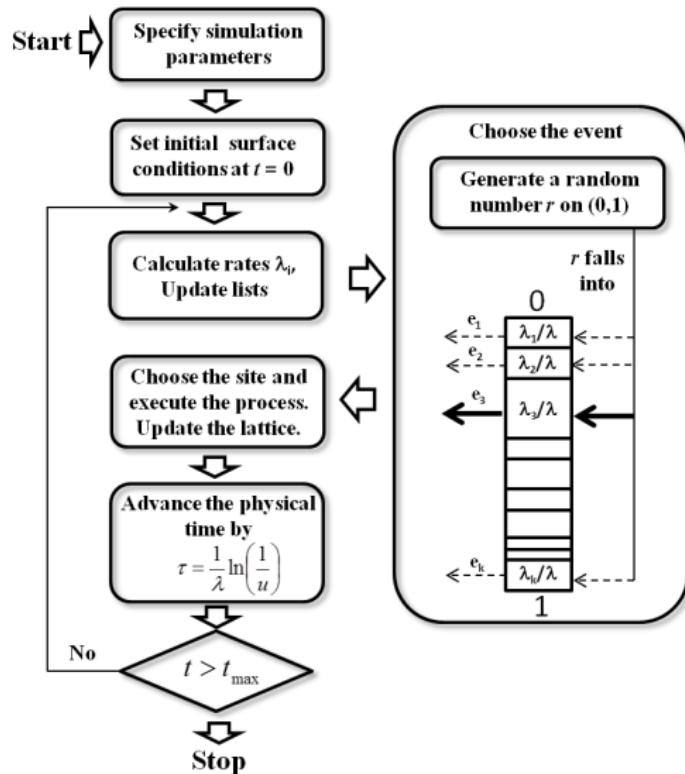
[A.B. Bortz, M.H. Kalos and J.L. Lebowitz, *J. Comput. Phys.* **17** (1975) 10]

[D.T. Gillespie, *J. Phys. Chem.* **81** (1977) 2340]

[V. Guerra and D. Marinov, *Plasma Sources Sci. Technol.* **25** (2016) 054001]

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The n -fold way (BKL) algorithm flowchart

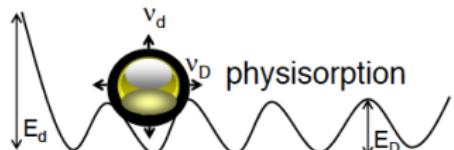


Transition rates

- Desorption: $r_d = \nu_d \exp(-E_d/kT_w)$

- $\nu_d \sim 10^{15} \text{ s}^{-1}$

- $E_d \sim 0.5 \text{ eV} (\sim 50 \text{ kJ/mol})$



- Adsorption: $r_f = k'_f \phi_A/[F]$, $r_s = k'_s \phi_A/[S]$

Credits: D. Marinov

- $[F] \sim 10^{15} \text{ cm}^{-2}$; $[S] \sim 10^{13} \text{ cm}^{-2}$

- $k'_f \sim 1$

- Recombination: $P_R = \exp(-E_R/kT_w)$

- $E_R \sim 0.2 \text{ eV} (\sim 20 \text{ kJ/mol})$

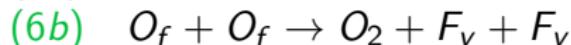
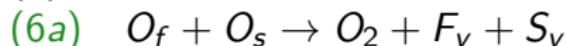
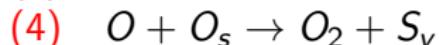
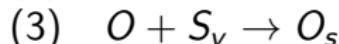
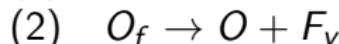
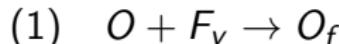
- Surface diffusion: $r_D = \nu_D \exp(-E_D/kT_w)$

- $\nu_d \sim 10^{13} \text{ s}^{-1}$

- $E_D \sim E_d/2$

The transition rates can differ by 10 orders of magnitude!

O recombination in O₂



$$[F] = 1.5 \times 10^{15} \text{ cm}^{-2}$$

$$E_d = 30 \text{ kJ/mol}; \nu_d = 10^{15} \text{ s}^{-1}$$

$$[S] = 3 \times 10^{13} \text{ cm}^{-2}$$

$$E_R = 17.5 \text{ kJ/mol}$$

$$E_D = E_d/2; \nu_D = 10^{13} \text{ s}^{-1}$$

$$E_R = 17.5 \text{ kJ/mol}$$

$$E_R = 0$$

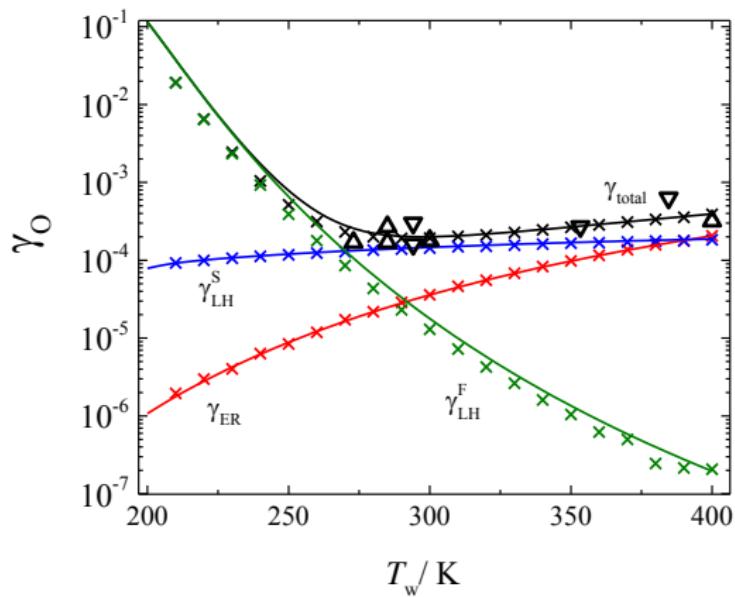
- At steady-state:

$$\gamma = 2 \left(\frac{\theta_s (\textcolor{red}{r_4} + \theta_f \textcolor{green}{r_{6a}})[S] + \theta_f \theta_f \textcolor{green}{r_{6b}}[F]}{\phi_O} \right) = \textcolor{red}{\gamma_{ER}} + \textcolor{green}{\gamma_{LH}^s} + \textcolor{green}{\gamma_{LH}^f}$$

- γ_{LH}^f may be dominant at intermediate pressures (10-50 Torr)

[D. Lopaev *et al*, *J. Phys. D: Appl. Phys.* **44** (2011) 015201]

γ_O vs T_w

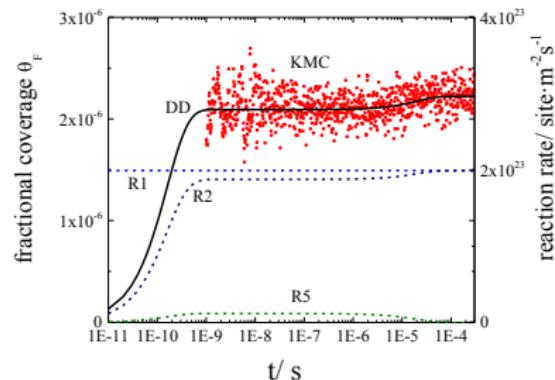


$[O] = 10^{15} \text{ cm}^{-3}$; \times KMC; $(—)$ DD

\triangle [Y.C. Kim and M. Boudart, *Langmuir* **7** (1991) 2999]

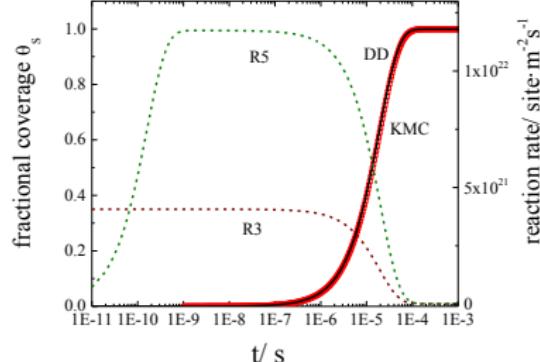
\triangledown [J.C. Greaves and J.W. Linnett, *Trans. Faraday Soc.* **55** (1959) 1355]

Adsorption kinetics at $T_W = 300$ K



R₁: physisorption

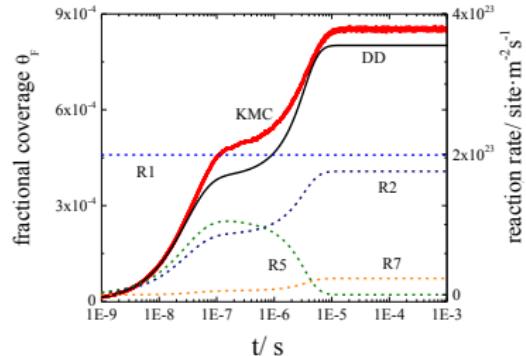
R₃: chemisorption



R₂: thermal desorption

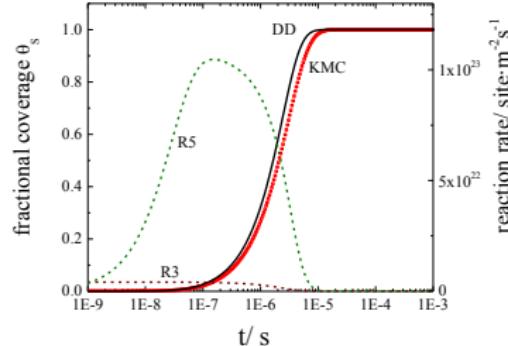
R₅: surface diffusion

Adsorption kinetics at $T_W = 200$ K



R₁: physisorption

R₃: chemisorption



R₂: thermal desorption

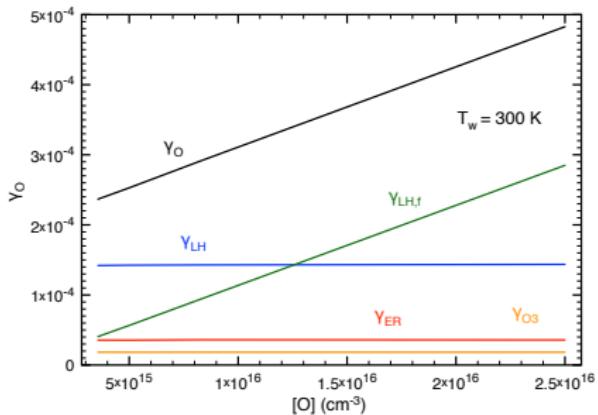
R₅: surface diffusion

O recombination with formation of O₂ and O₃

- | | | |
|------|---|---|
| (1) | $O + F_v \rightarrow O_f$ | $[F] = 1.5 \times 10^{15} \text{ cm}^{-2}$ |
| (2) | $O_f \rightarrow O + F_v$ | $E_d = 30 \text{ kJ/mol}; \nu_d = 10^{15} \text{ s}^{-1}$ |
| (3) | $O + S_v \rightarrow O_s$ | $[S] = 3 \times 10^{13} \text{ cm}^{-2}$ |
| (4) | $O + O_s \rightarrow O_2 + S_v$ | $E_R = 17.5 \text{ kJ/mol}$ |
| (5) | $O_f + S_v \rightarrow F_v + O_s$ | $E_D = E_d/2; \nu_D = 10^{13} \text{ s}^{-1}$ |
| (6a) | $O_f + O_s \rightarrow O_2 + F_v + S_v$ | $E_R = 17.5 \text{ kJ/mol}$ |
| (6b) | $O_f + O_f \rightarrow O_2 + F_v + F_v$ | $E_R = 0$ |
| (11) | $O_2 + F_v \rightarrow (O_2)_f$ | $k' = 1$ |
| (12) | $(O_2)_f \rightarrow O_2 + F_v$ | $E_d = 17.5 \text{ kJ/mol}; \nu_d = 10^{15} \text{ s}^{-1}$ |
| (13) | $O_f + (O_2)_f \rightarrow O_3 + 2F_v$ | $E_R = 0$ |

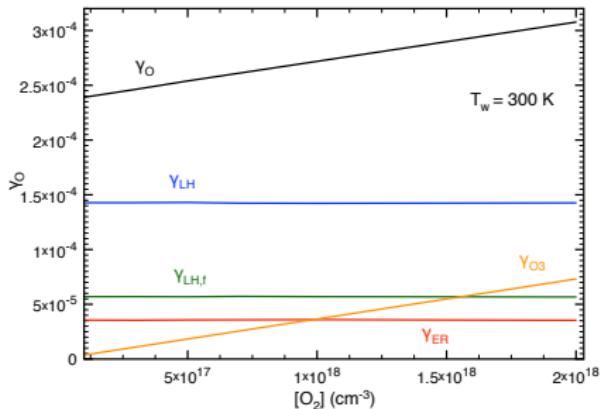
[Lopaev *et al* 2011]: $E_d^{O_2} \simeq 18.3 \text{ kJ/mol}$; $E_d^O \simeq 31.6 \text{ kJ/mol}$

Recombination probability



$$[O_2] = 5 \times 10^{17} \text{ cm}^{-3}$$

$\gamma_{LH}^{O_2}$ ($\sim 3 \times 10^{-5}$) is about one order of magnitude lower than in [Lopaev et al 2011]
[D. Marinov et al, PSST 22 (2013) 055018]: $\gamma_{LH}^{O_2} < 10^{-4}$ at $p = 5$ Torr



$$[O] = 5 \times 10^{15} \text{ cm}^{-3}$$

Conclusions

- Modelling constitutes a powerful tool to understand, predict and optimize the plasma behaviour
- A comprehensive kinetic model has been developed to study oxygen discharges . . . associated with the LoKI simulation tool
- Oxygen exhibits a highly excited VDF, as a result of significant e-V rates
 - “But to what purpose / (. . .) / I do not know.”
- vibrationally excited ozone plays an important role in O_3 kinetics
- Formation of ozone at surfaces could not be established at the present conditions
- Upper limits for $\gamma(O_3)$ were established at 10^{-5} and 10^{-4} for $p = 1$ and 5 Torr, respectively, in good agreement with [Lopaev *et al* 2011]

Conclusions (continued)

- Powerful Kinetic Monte Carlo algorithms are available to simulate surface kinetics and coupled gas phase and surface chemistries
 - A variant of the n -fold way algorithm was used to investigate systems with rates varying over 10 orders of magnitude (!)
 - O recombination on silica:
 - reactions involving physisorbed O and O_2 dominate the surface kinetics
 - the complex behaviour of γ_O with T_W was interpreted
 - O_3 formation on surfaces was described, in fair agreement with experimental data
- ⇒ Coupled with MD, *Dynamical Monte Carlo methods constitute a powerful tool to simulate surface processes* up to large space/time scales
- Near future: explore the impact of a distribution of reactivity

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